

Title (en)

Random trans SBR with low vinyl microstructure

Title (de)

Statistisches SBR mit hohem Transgehalt und niedrigem Vinylgehalt

Title (fr)

SBR statistique à haute teneur en trans et à basse teneur en vinyl

Publication

**EP 0877034 A1 19981111 (EN)**

Application

**EP 98107597 A 19980427**

Priority

US 4558697 P 19970505

Abstract (en)

The process and catalyst system of this invention can be utilized to synthesize a highly random styrene-butadiene rubber having a high trans content by solution polymerization. The styrene-butadiene rubber made by the process of this invention can be utilized in tire tread rubbers that exhibit improved wear characteristics. This invention more specifically reveals a catalyst system for use in thiothermal polymerizations which consists essentially of (a) an organolithium compound, (b) a barium alkoxide and (c) a lithium alkoxide. The subject invention further discloses a process for synthesizing a random styrene-butadiene rubber having a low vinyl content by a process which comprises copolymerizing styrene and 1,3-butadiene under isothermal conditions in an organic solvent in the presence of a catalyst system which consists essentially of (a) an organolithium compound, (b) a barium alkoxide and (c) a lithium alkoxide.

IPC 1-7

**C08F 36/04**; **C08F 4/54**; **C08F 236/10**

IPC 8 full level

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CPC (source: EP KR US)

**C08F 4/48** (2013.01 - KR); **C08F 4/565** (2013.01 - EP US); **C08F 236/10** (2013.01 - EP US); **Y02T 10/86** (2013.01 - EP US)

Citation (search report)

- [DA] US 5100965 A 19920331 - HSU WEN-LIANG [US], et al
- [A] US 3903019 A 19750902 - HARGIS IVAN GLEN, et al

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